Inspects NanoSpace

ATOMIC FORCE MICROSCOPE

ara-research.com

Inability of optical microscopes in imaging sizes smaller than wavelength of visible light resulted in invention of nanoscopes in the last decades. AFM is the top in the list due to its low price and multi-applications.

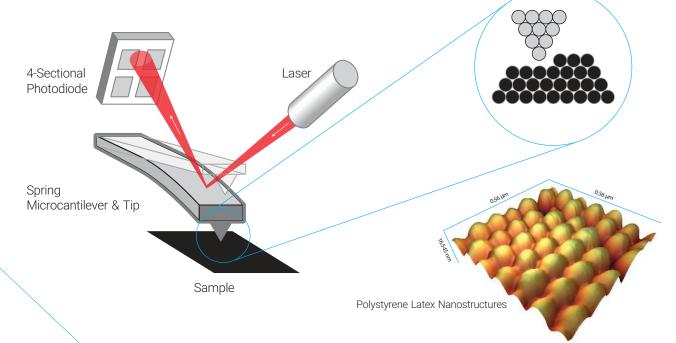
The basic principle of AFM

A spring micron size cantilever has a conical tip at its free end. The conical tip with a very sharp end, usually less than 10 nanometres, scans the sample surface from a very close nanometric distance.

As the tip moves over the surface the Van Der Waals forces between atoms on the sharp end of the tip and atoms on the surface of the sample varies, resulting vertical displacements of the cantilever.

Vertical movements of the cantilever are sensed by an optical method. The reflected laser beam from the cantilever backside hits a quadruple photodiode. The output signals of the photodiodes are related to the vertical movements of the cantilever which in turn represents the surface topography of the sample.

Nowadays AFM is the main tool in Nano research works. Apart from 3-dimensional nanoimaging, AFM is capable of determining various properties of the sample in nano scale. AFM could also perform nano-manipulations and nanolithography.



Our valuable experience in equipping over 80 universities and research centres to AFMs and our view to extend our market to all continents directed us to a new design on the technology edge.

- » Elegant and innovative appearance, modest volume.
- » Extremely user friendly; eliminating strains on users.
- » Nano imaging in least possible time duration.
- » Robustness



The above features, plus using the latest technologies in manufacturing ARA-AFM, has produced an splendid apparatus for nano researchers. Ara Research, with 30 years of experience in producing nano technology equipment, today is setting forth the sophisticated functioning modes of AFM in an spectacular product.

control of high-tech products



Solar cells, semiconductors and integrated circuits

Surface engineering material







Pathology and medicine synthesis medical science



Ceramics

and coatings

Nano-scale

mechanical

and electrical

properties

Biotechnology research



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- Simplified procedure for nano-imaging Simplifications in operation together with reducing the required time for nano-imaging has made ARA-AFM extremely user friendly.
- Developed tip fixing procedure You can calmly fix the tip in AFM-head in the shortest possible time.
- High magnification OM The initial imaging for choosing the scan point is performed using a powerful OM fixed on the machine.
- Adopted with all computer types PCs, laptops, all-in-one or any other computer types can be used with ARA-AFM.

» New generation of the controller

Employing the latest advanced electronics in ARA-AFM has improved the controller functioning.

\gg LAN feature

One single network cable does all data transfer between computer and the machine.

>> Fast Approach

Saving time during approach by using fast approach technique is a marvellous feature of ARA-AFM.

Fantastic design, compact

ARA-AFM occupies least possible space in your laboratory and its nice looking view attracts the users.







Direct online communication

Network possibility provides simultaneous connection of technical specialist and the user to ARA-AFM. This feature speeds up user's problem solving and troubleshooting. Further, one may operate ARA-AFM from any station in network and no need to be present in the lab.



Developed software

Highly-magnified tip and sample view, obtaining & auto-saving nano images and signals monitoring are unique features of the latest version of ARA-AFM software.



Straight and easy tip-fixation

Thanks to the new head design, providing the easiest way of fixing the tip without usual user's stress. Picking and putting of the tip is performed with the least possible risk of breakage.



Time saving in approach

Swift commence of scanning is due to sophisticated fast approach technique implemented in ARA-AFM.

SPECIFICATIONS

Scanner XY scanner 20 - 70 µm maximum XY scan range 1 nm XY resolution Z scanner 4 µm maximum Z movement range 0.1 nm Z resolution		Electronics Plug and Play control box ADC and DAC channels 4 channel ADC 24bit 4 channel DAC 24bit Signal processing 40 MHz frequency zynq processor Integrated functions 100 MB/sec via LAN	
Stage XY stage Motorized software-controlled 15 mm travel range 40 nm movement steps Z stage 15 mm travel range 40 nm movement steps Automatic engage of the cantilever to the Sample surface (Auto Fast Approach) Sample Mount 20 mm maximum sample diameter 10 mm maximum sample thickness Includes light magnetic sample holder		Software Data acquisition Real-time 100 MB/sec microsoft windows compatible Integrated optical view windows for sample and cantilever vision Monitoring all system signals with a high rated oscilloscope Auto saving captured images in software gallery Scanning zoom-selected area on captured images Automatic fast approach of cantilever to the sample surface (Auto Fast Approach) Image processing Independent software for image processing, data analysis and presentation	
 -10 V to +10 V bias voltage range to the sample Top Veiw Optical Microscope 8-megapixel resolution, color 60X to 600X optical zoom Integrated lighting Include microscope dimmer 		Capability of exporting different data of images Built-in with all Microsoft OS Dedicated all in one (AIO) computer 21" Display monitor: 1920 *1080 resolution The latest generation of processors 8 GB RAM	
HeadHigh precision adjustment micrometer670 nm laser wavelength5 mW maximum laser diod powerHigh grade quadruple photo-diodeDithering mechanismOptimized optical path designSpring lever tip holder mechanism		AFM Unit Plug and Play Dimension 300 mm × 400 mm × 300 mm Net Weight 20 Kg	
Accessories Sample mounting kit The sample substrate Various types of cantilevers Tweezers and magnet box		OptionsXY scannerPossibility to customize the XY scan rangeto 100 μmTip changing kitVacuum pen	
Standard Modes: Contact, Non-Contact, Tapping			
Functional Kits			
Fly Kit Magnetic Force Microscopy (MFM) Electric Force Microscopy (EFM) Phase Imaging	Pro Contact Kit Lateral Force Microscopy (LI Force spectroscopy Mechanical nano-lithography		Experts Kit Chemical nano-lithography Force Modulation Microscopy (FMM) Conductive AFM (C-AFM) Kelvin Probe Force Microscopy (KPFM) Discorresponde Force Microscopy (DEM)

• Any requirement for specific applications or modification can be customized

Piezoresponse Force Microscopy (PFM)



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